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(54) Title: POLYETHER COMPOSITION

(57) Abstract: An object of the present invention is to provide a polyether composition that can suppress reduction in a molecular weight of polyether having a low glass transition temperature and melting point. As a means of achieving this object, a polyether composition of the present invention contains polyether having a glass transition temperature of -50 oC or lower and a melting point of 55 °C or lower and, at the same time, contains at least one kind selected from the group consisting of compounds represented by the specified three general formulas.

